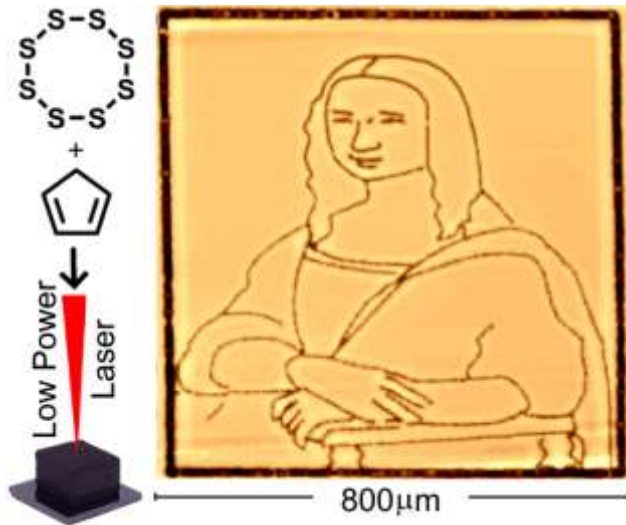
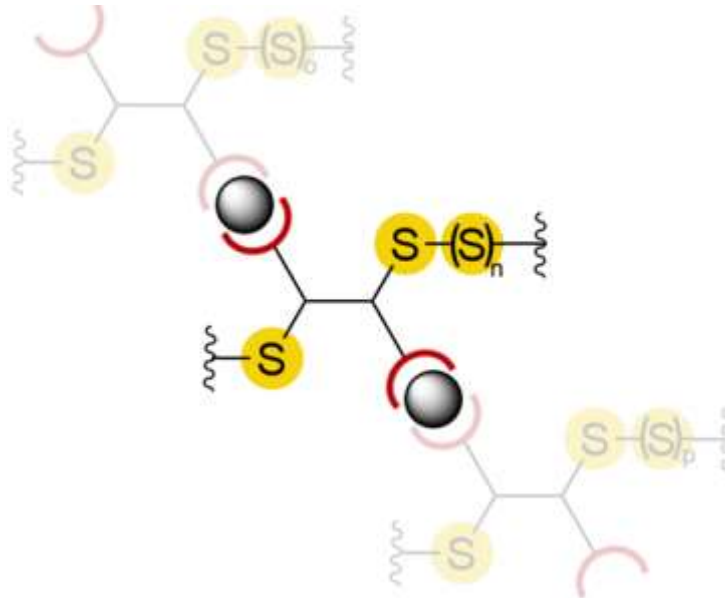


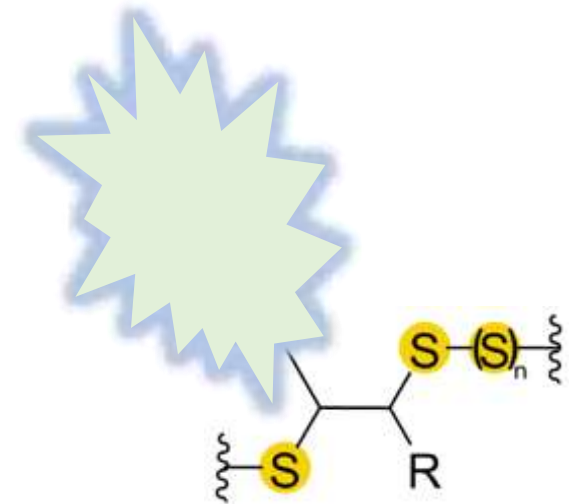
# Functionalising Sulfur Polymers



Lithography and Erasable Encoding

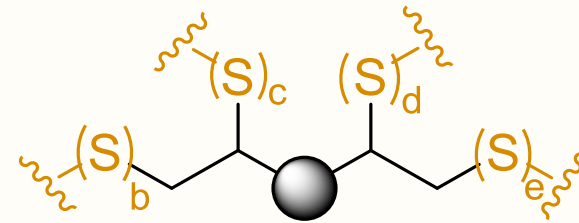
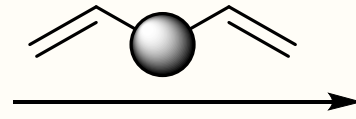
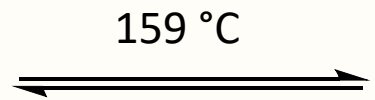
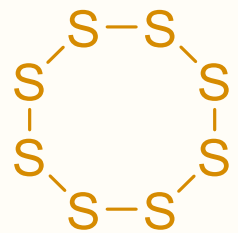


Water Solubility and Metal Binding

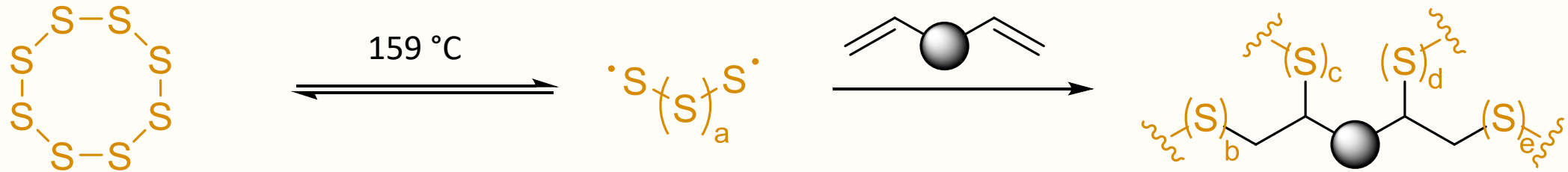


Fluorescence Imaging

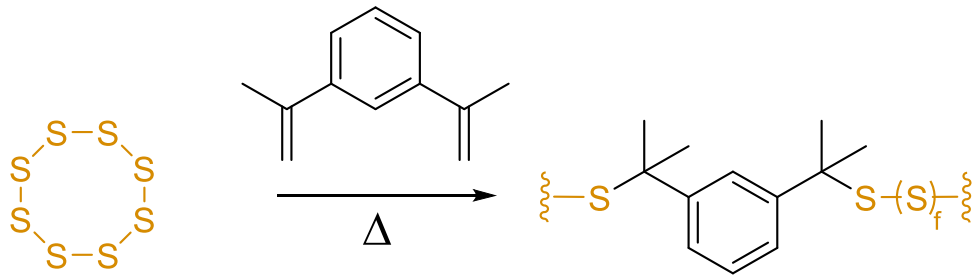
# Inverse Vulcanisation



Sung Y-E., Char K., Pyun J., et al., *Nat. Chem.* **2013**, 5, 518-524



Sung Y-E., Char K., Pyun J., et al., *Nat. Chem.* **2013**, 5, 518-524



Pyun J., et al. *J. Am. Chem. Soc.* **2023**, 145, 12386-12397

## Li-S Batteries

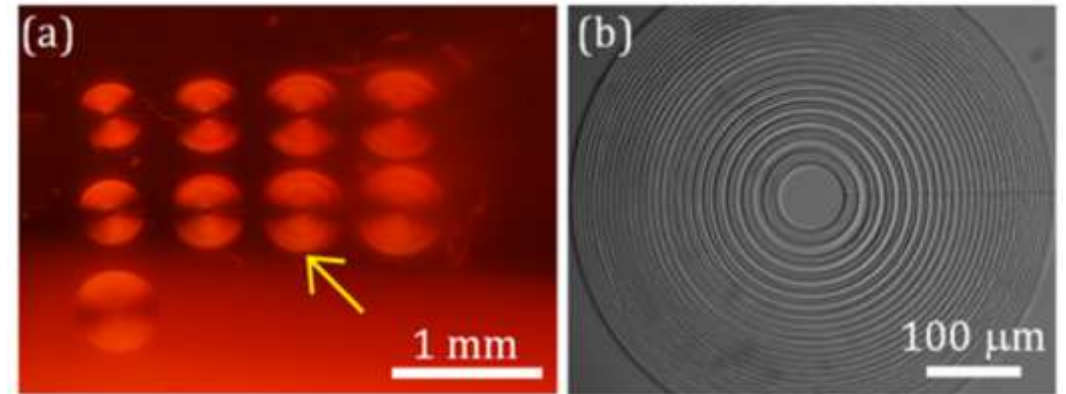
Pyun J., et al. *ACS Macro Lett.* **2014**, 3, 229-232

## IR Optics

Pyun J., et al. *Adv. Mater.* **2014**, 26, 3014-3018

## Dynamic Repairable Materials

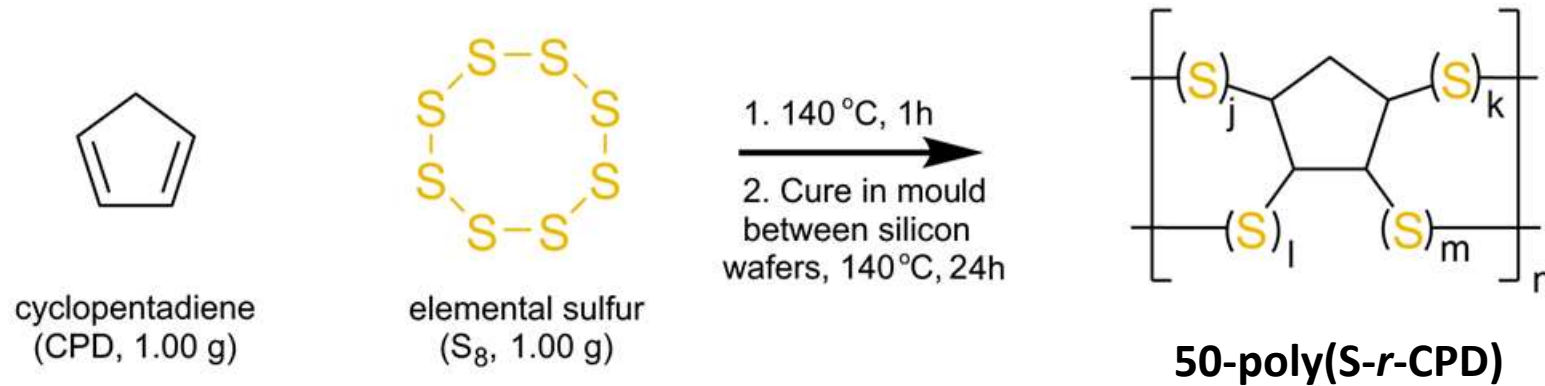
Pyun J., et al. *ACS Macro Lett.* **2015**, 4, 862-866



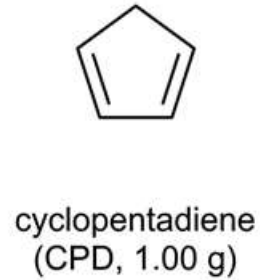
## High-powered pulsed laser etching

Zhao J., et al. *Opt. Lett.* **2023**, 48, 1056-1059  
Zhao J., et al. *Opt. Mater. Express* **2022**, 12, 2541-2549

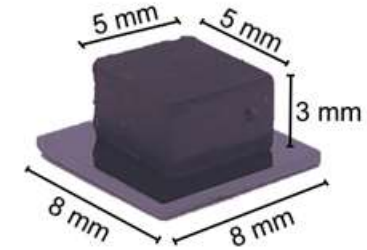
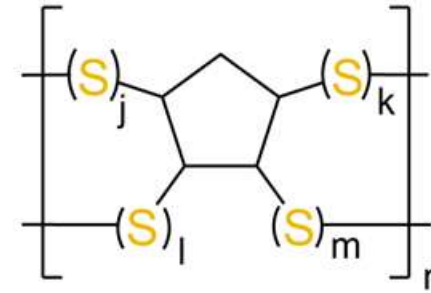
# Lithography and Information Encoding



# Lithography and Information Encoding



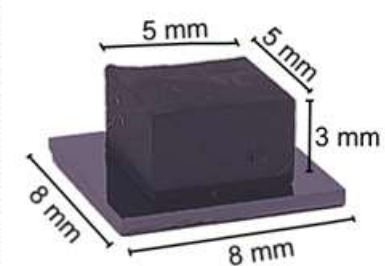
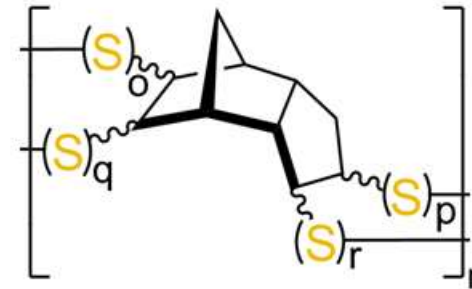
1. 140 °C, 1h  
2. Cure in mould  
between silicon  
wafers, 140 °C, 24h



$T_g = \sim 40 \text{ }^\circ\text{C}$   
 $R_a = 109 \text{ nm} \pm 5 \text{ nm}$



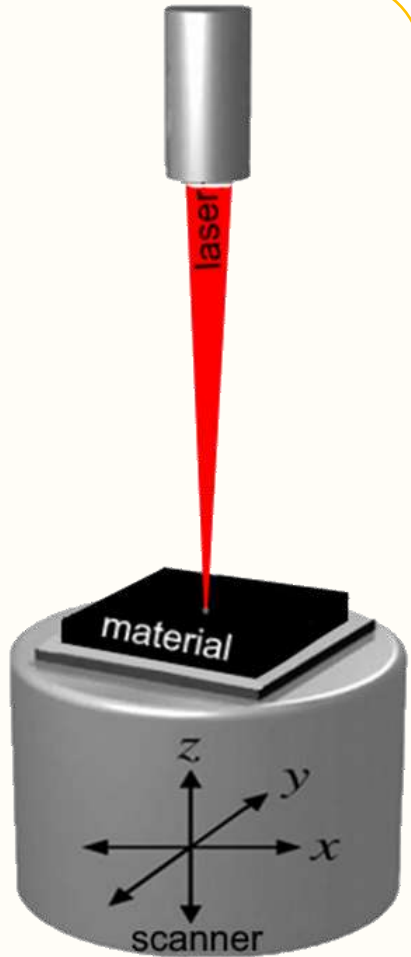
1. 140 °C, 2h  
2. Cure in mould  
between silicon  
wafers, 140 °C, 24h



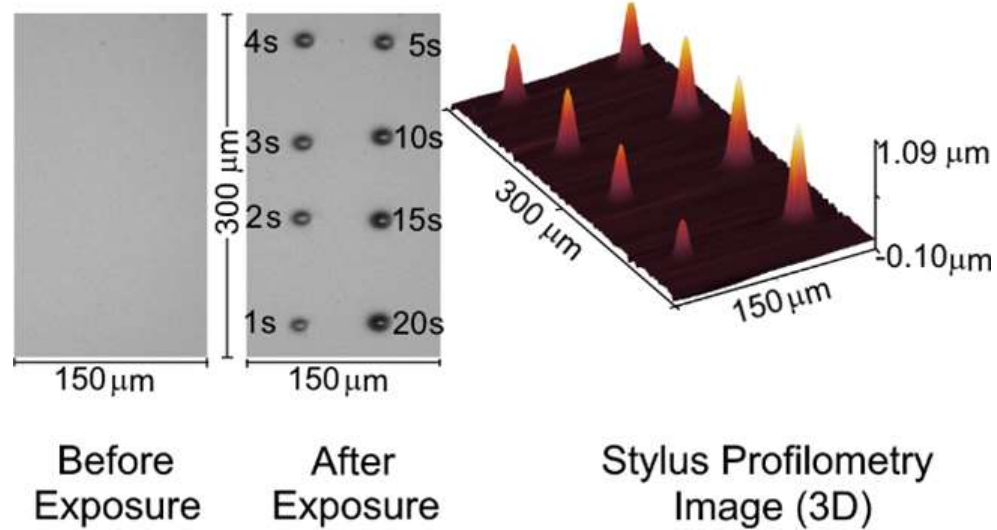
$T_g = >100 \text{ }^\circ\text{C}$   
 $R_a = 109 \text{ nm} \pm 1 \text{ nm}$

# Lithography and Information Encoding

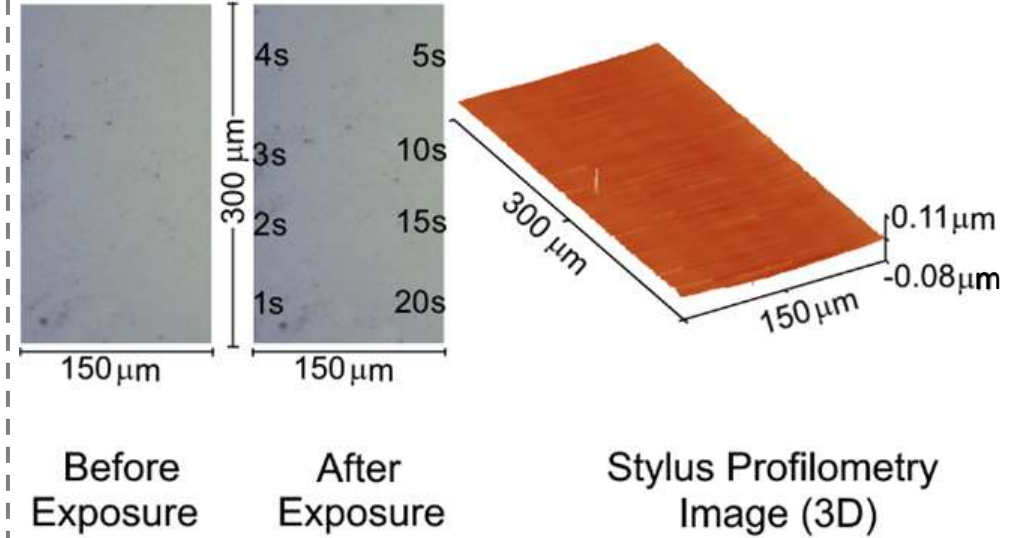
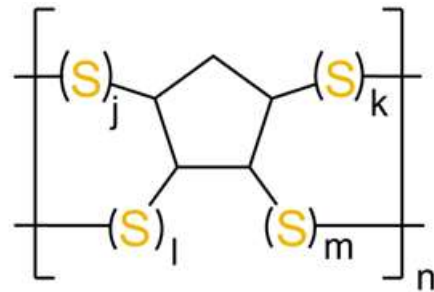
4/10



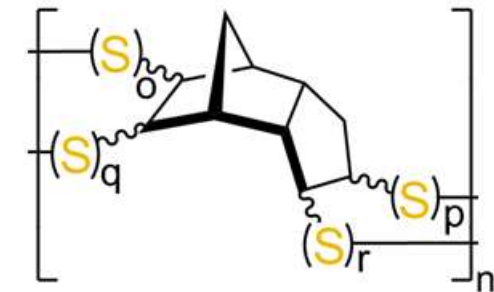
690 nm, 1.10 mW,  
1.4 kW/cm<sup>2</sup>  
**Low Power Laser**



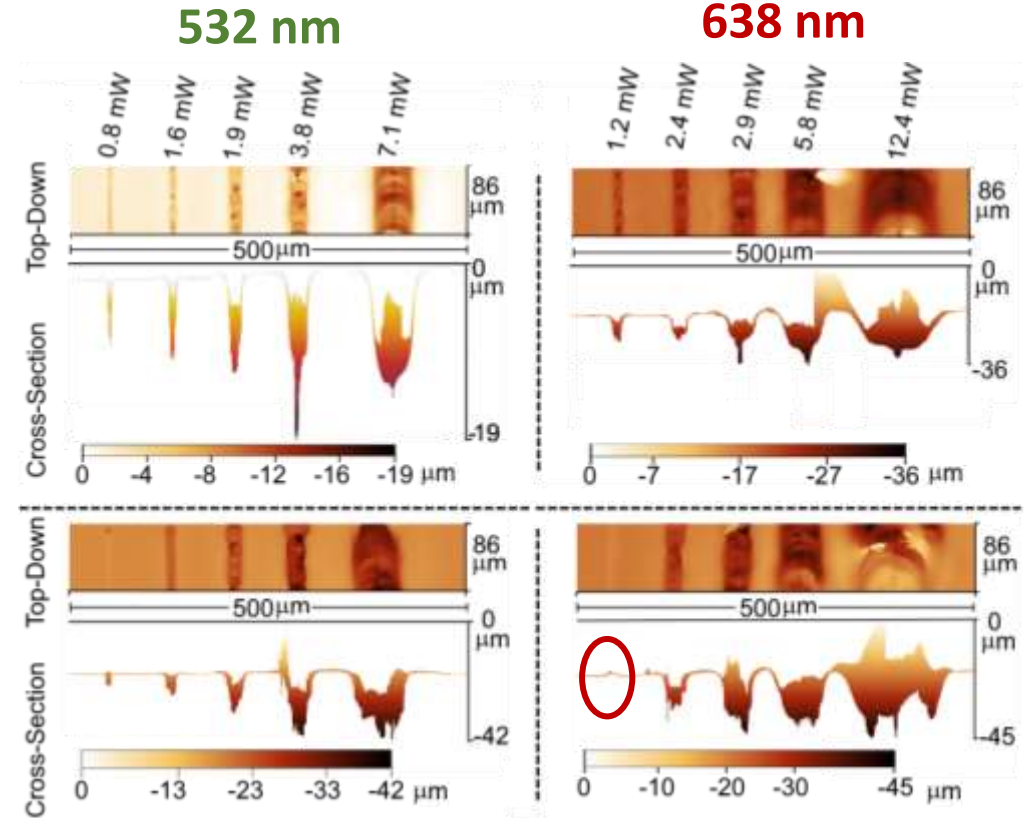
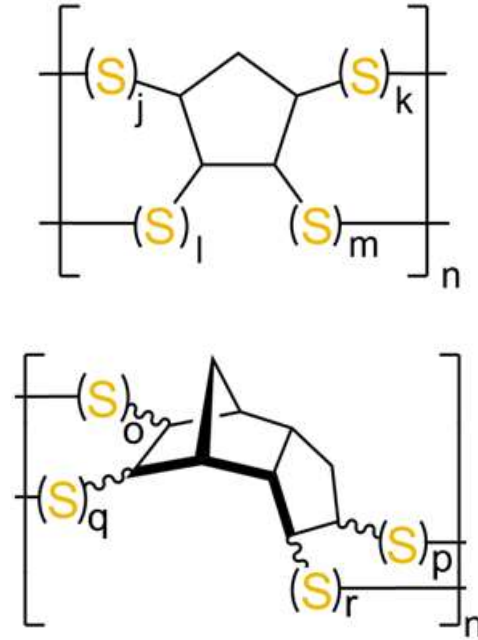
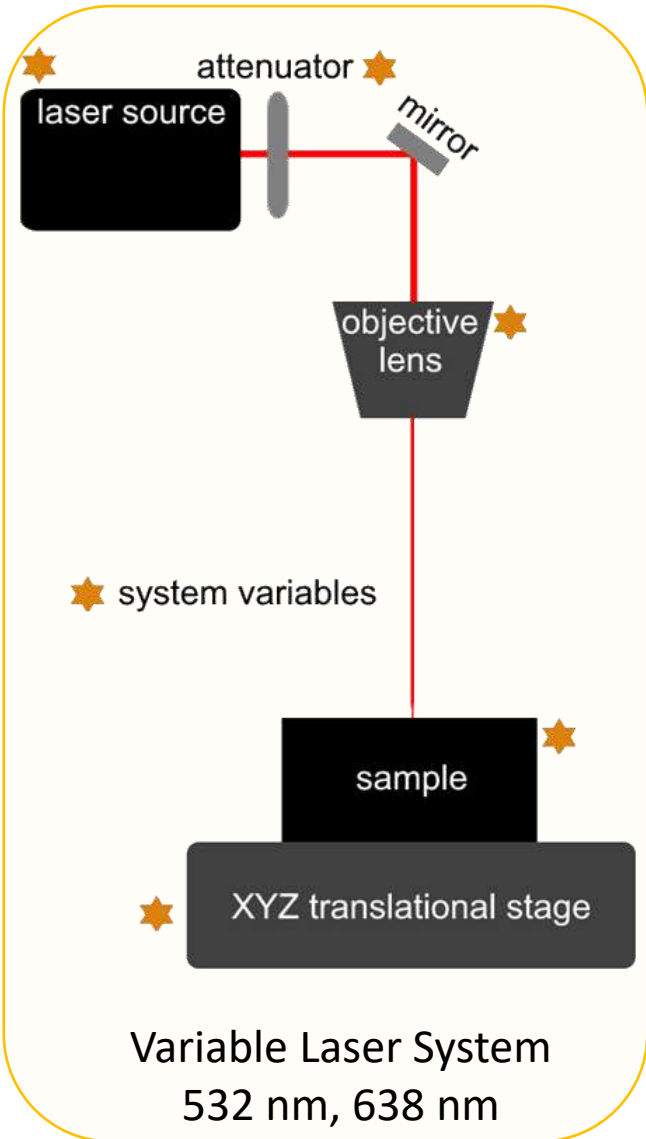
**50-poly(S-r-CPD)**



**50-poly(S-r-DCPD)**

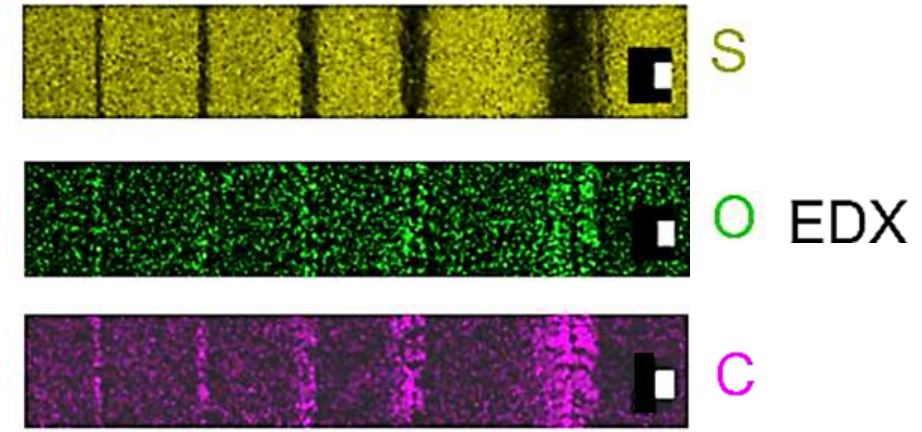
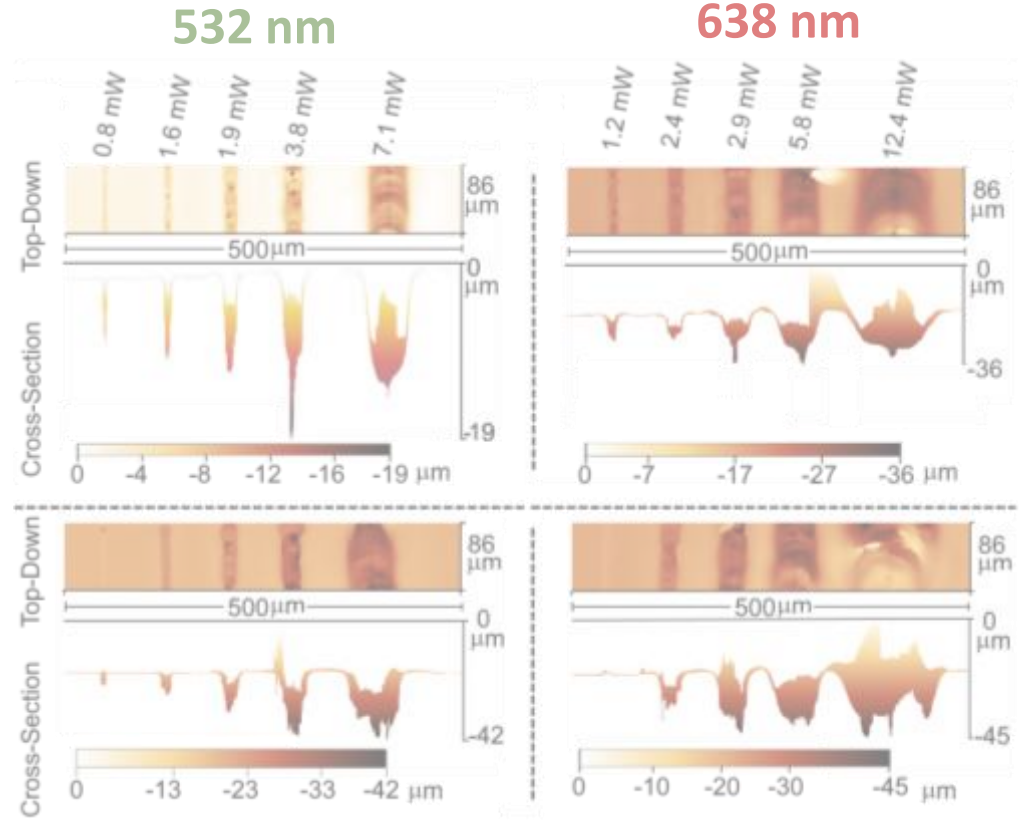
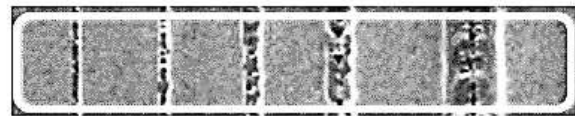
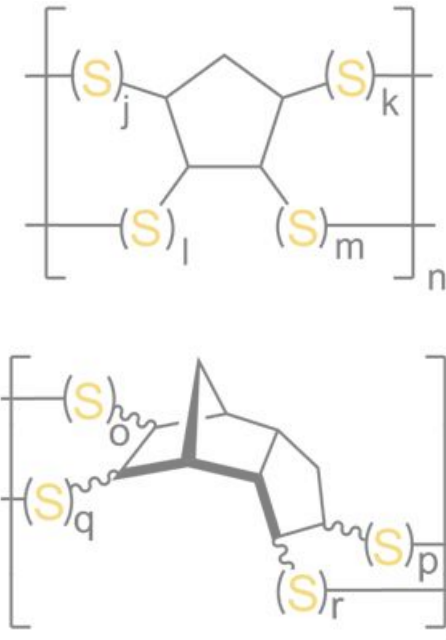
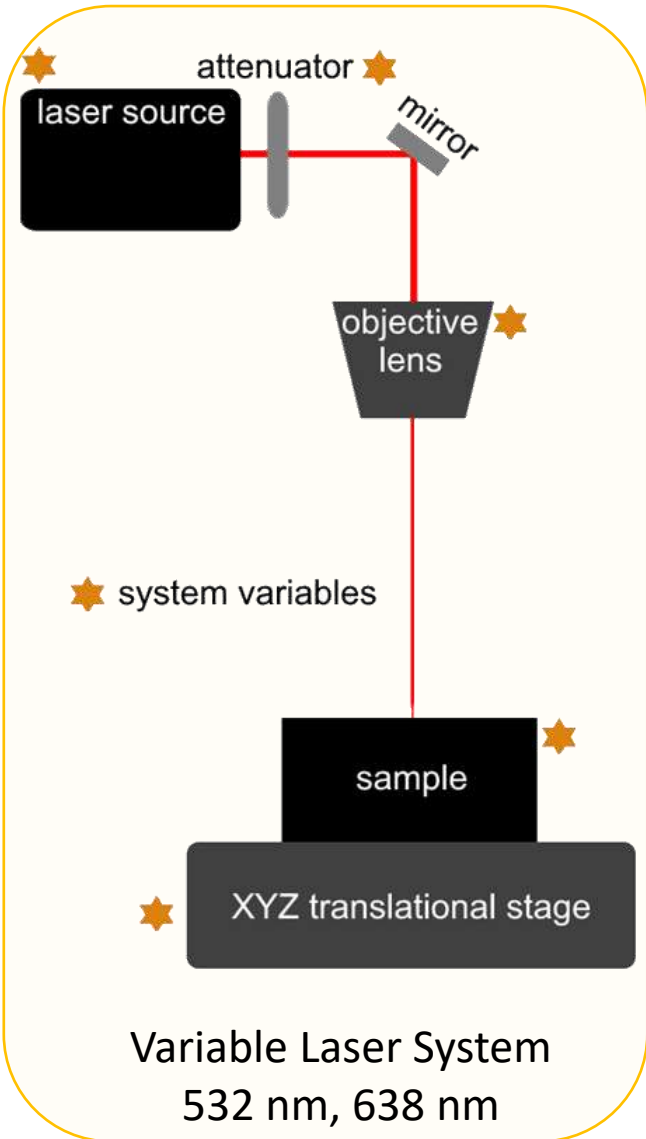


# Lithography and Information Encoding



Optical Profilometry

# Lithography and Information Encoding

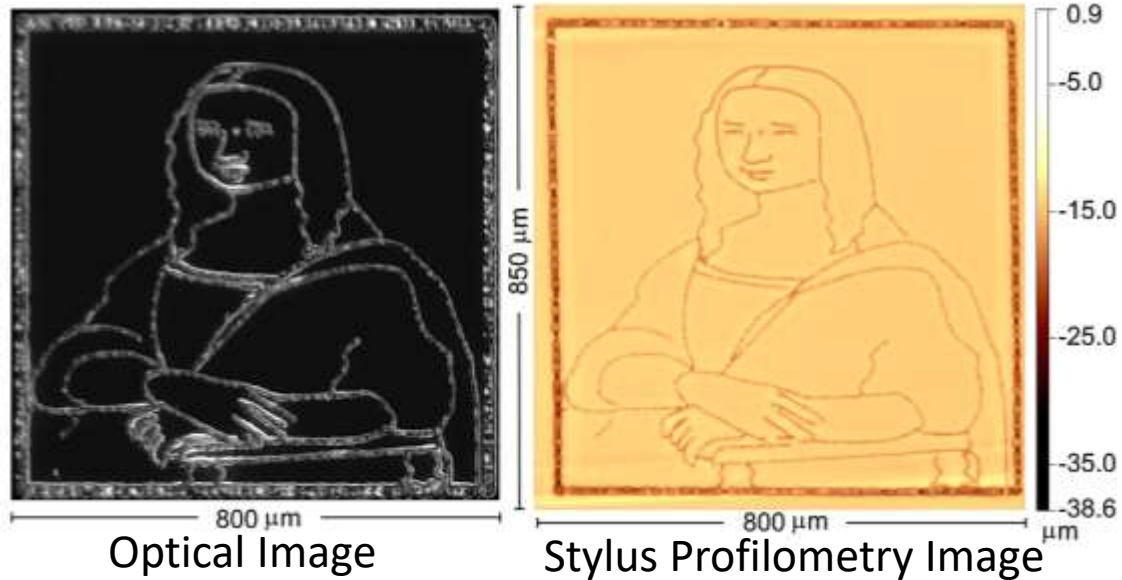
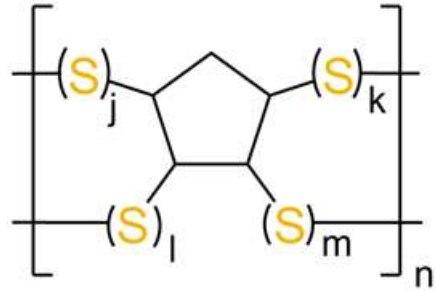




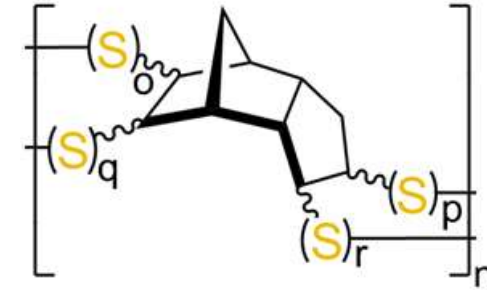
# Lithography and Information Encoding

## Programmable lithography – Micro-lisa

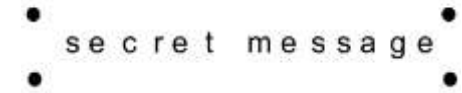
Reference Image



## Erasable information encoding



Text

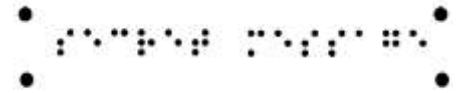


Optical Microscope Before



Optical Microscope After

Braille



Stylus Profilometry Before

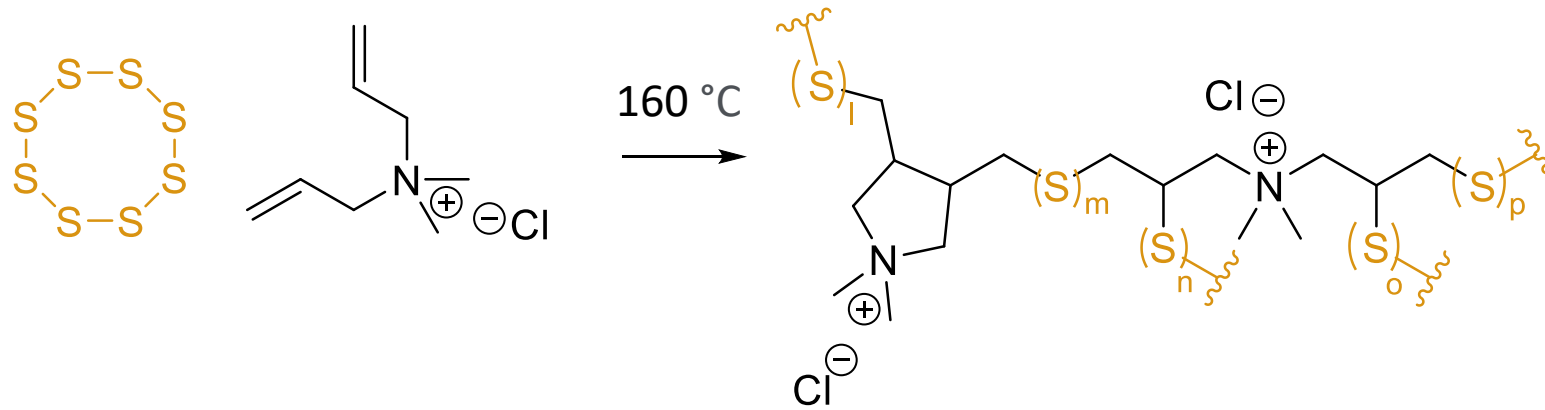


Stylus Profilometry After

Heat

# Water Solubility and Metal Binding

# Water Solubility and Metal Binding



**Water Soluble**

Jenkins, C. L., et al. *ACS Appl. Polym. Mater.* **2022**, *13*, 2782-2790



Polymer made with sulfur and canola oil

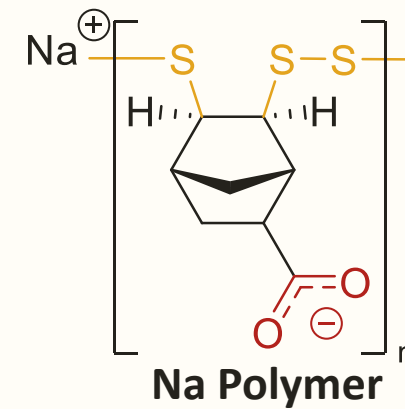
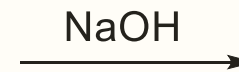
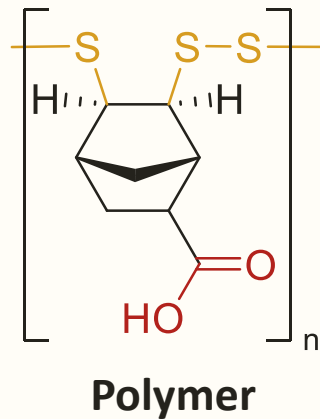
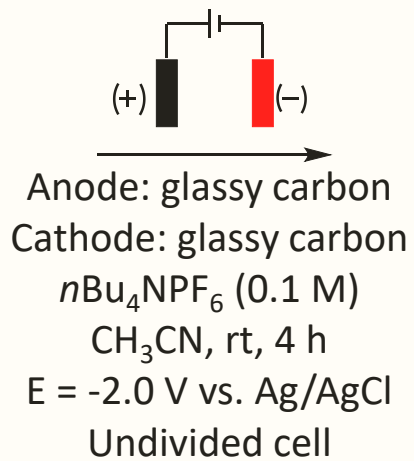
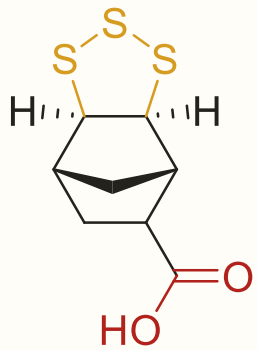
**Metal binding – Hg, Au, Pb, Ag**

Chalker J. M., et al. *Chem. Eur. J.* **2017**, *23*, 16219

Muller F. G., Lisboa L. S., Chalker J. M., et al. *Adv. Sustainable Syst.* **2023**, *23*, 2300010

# Water Solubility and Metal Binding

8/10

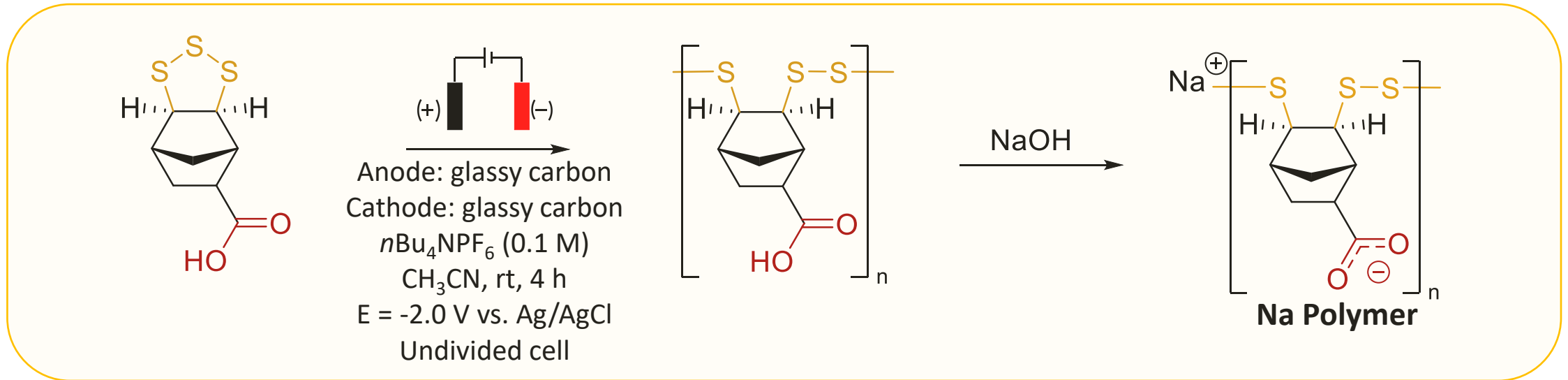


Polymer in Water  
**Insoluble**

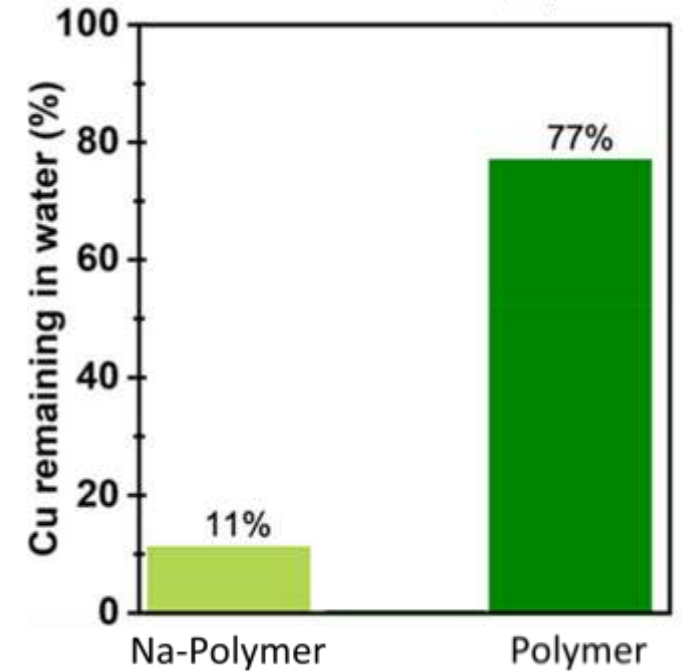
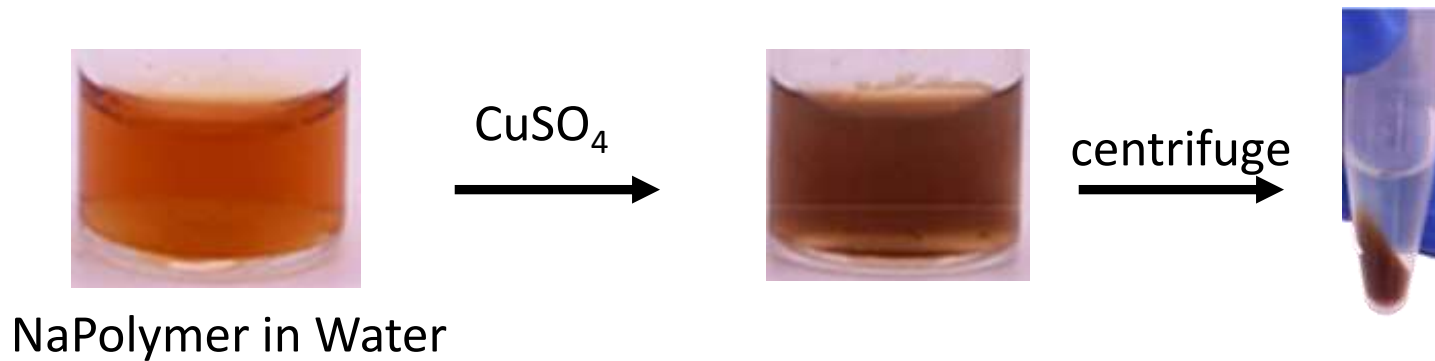


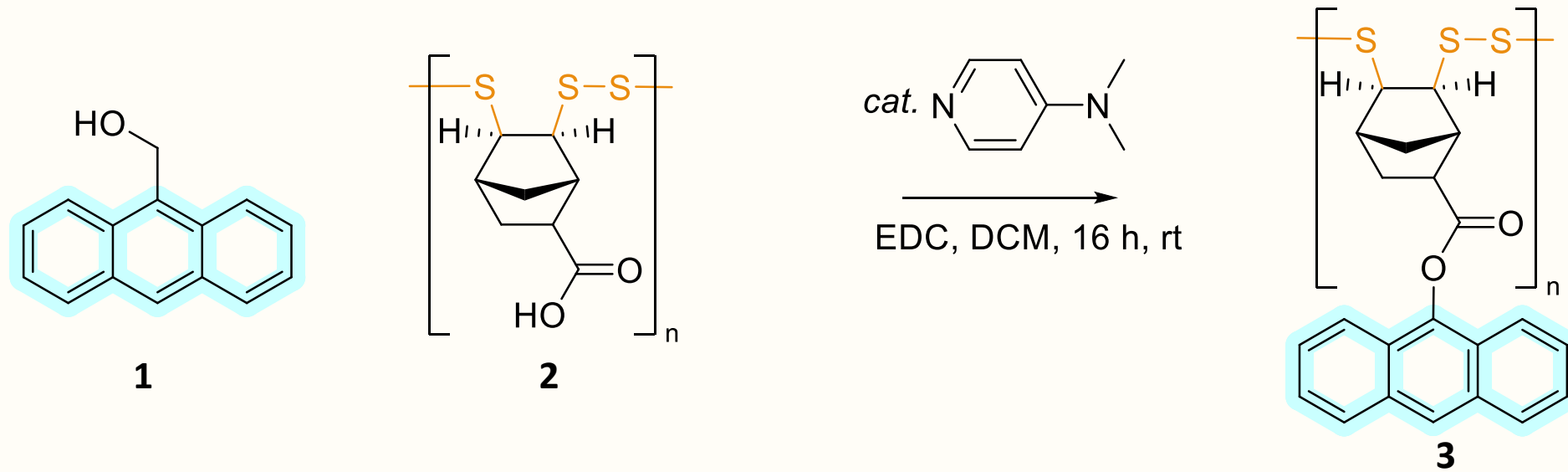
Na Polymer in Water  
**Soluble**

# Water Solubility and Metal Binding



## Copper Binding – 0.5:1 $\text{Cu}^{2+}/\text{COO}^-$





## Fluorescent polymers for biological imaging

- Quantify the number of fluorescent groups on the polymer
- Make a water-soluble fluorescent polymer
- Biological testing



365 nm,  $\text{CHCl}_3$

# Acknowledgements

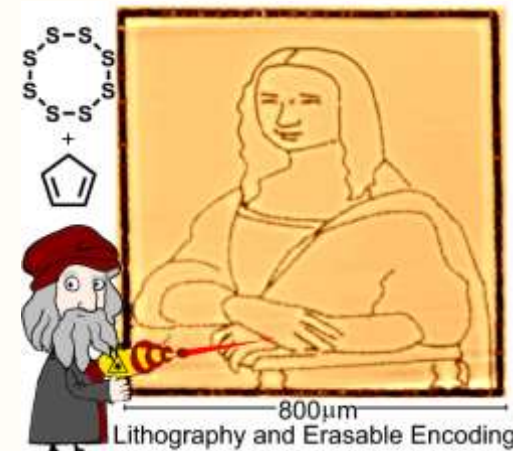
Prof Justin Chalker  
Dr Christopher Gibson  
Dr Jason Gascooke

Abigail Mann  
Samuel Tonkin  
Federico Müller  
Jasmine Pople  
Dr Harshal Patel  
Dr Yanlin Shi

The Chalker Group



Modification of Polysulfide Surfaces with Low-Power Lasers

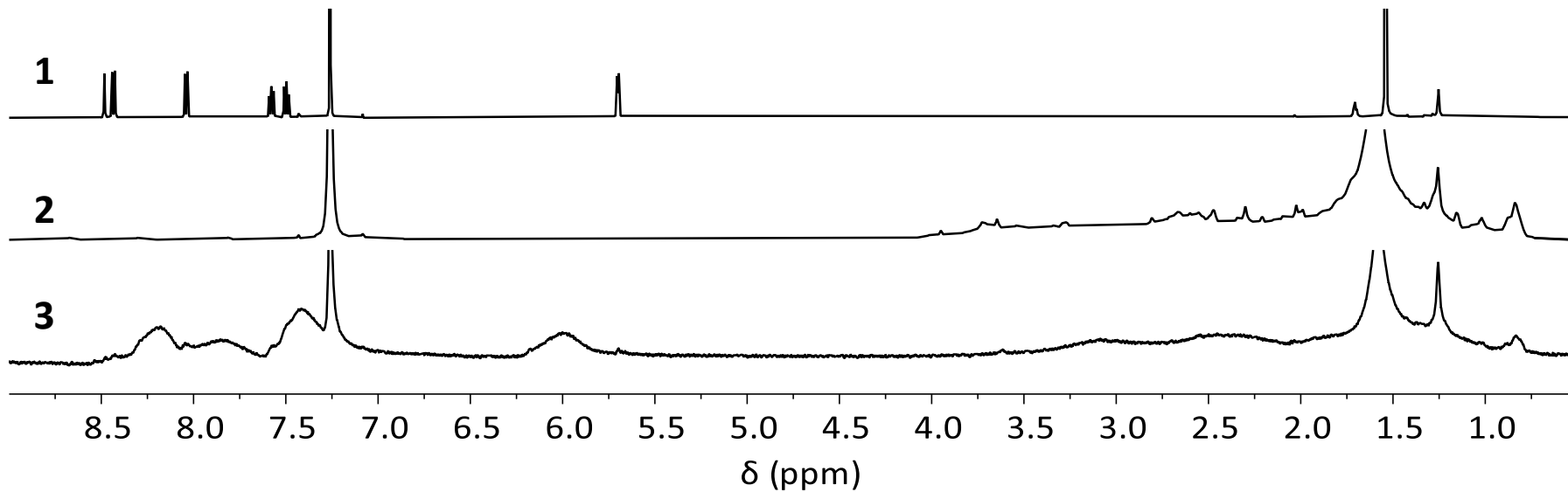
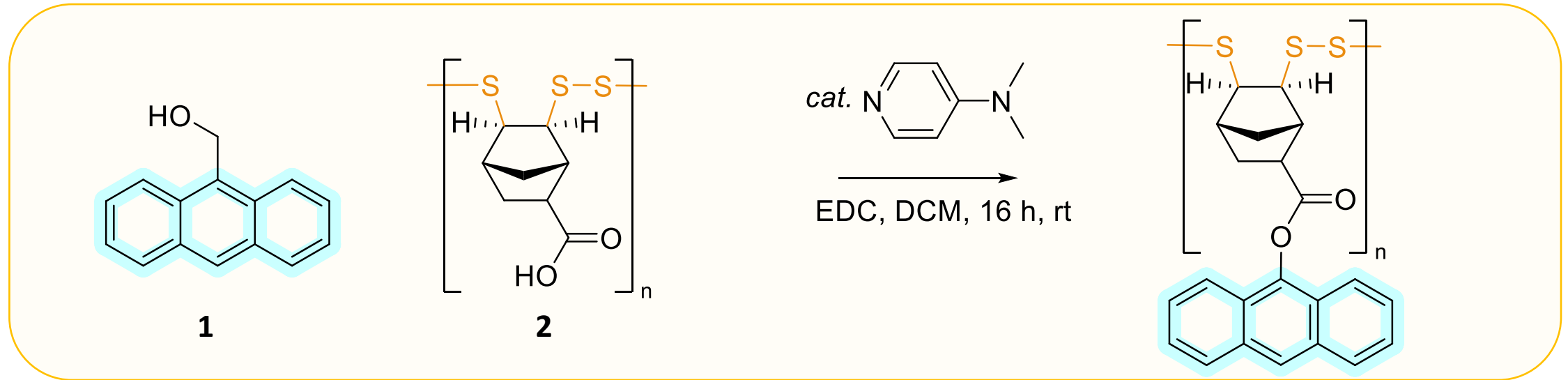


Coming Soon!





# Fluorescent Sulfur Polymers



Partial stacked  $^1\text{H}$  NMR (CDCl<sub>3</sub>, 298 K 600 MHz)



365 nm, CHCl<sub>3</sub>

# Fluorescent Sulfur Polymers

